

# IMPACT OF FIRING TEMPERATURE PROFILES ON LOCAL BSF FORMATION IN PERC SOLAR CELLS



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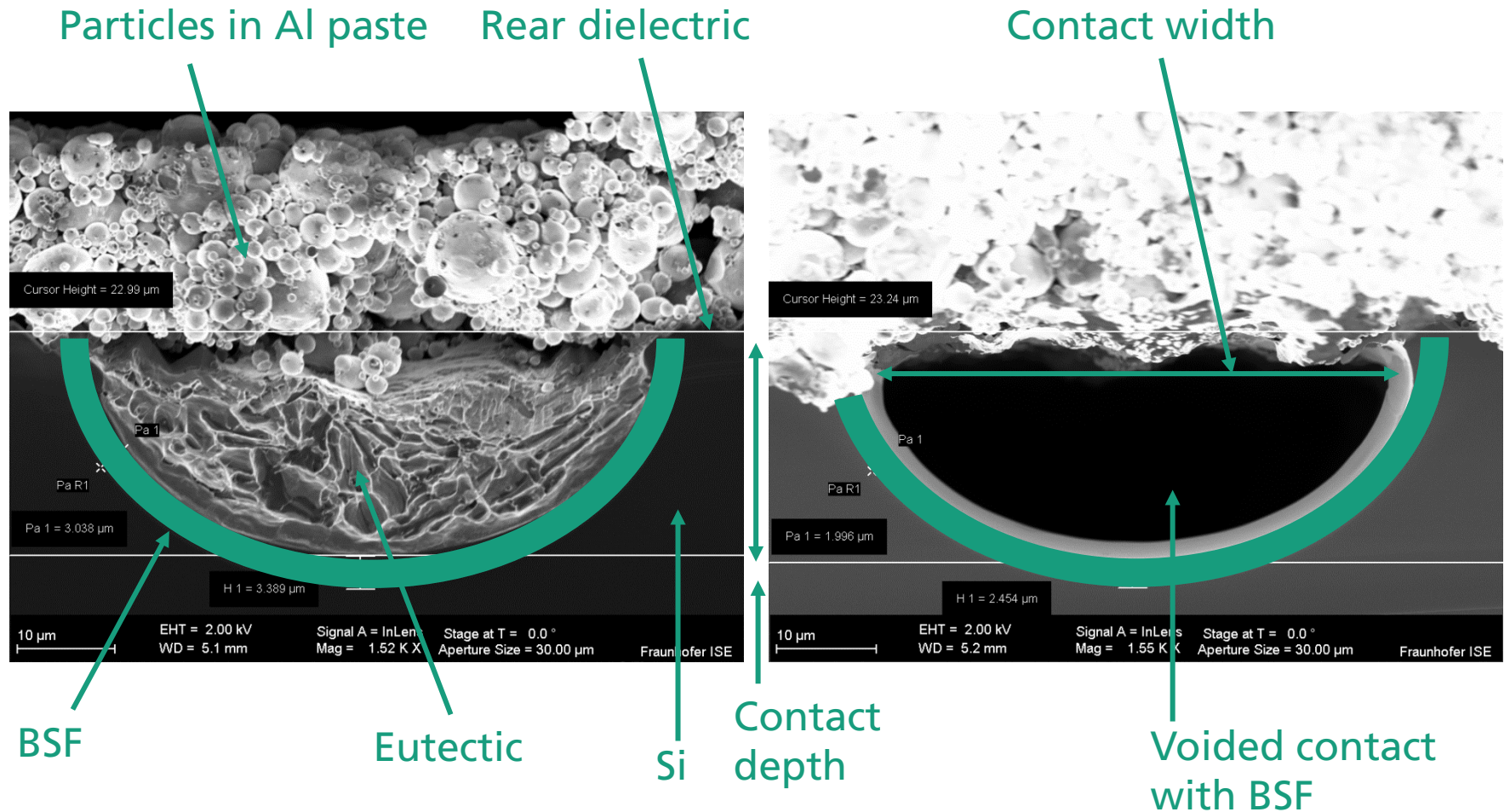
<sup>2</sup>BTU International Inc.

Konstanz, 03.05.2016

[www.ise.fraunhofer.de](http://www.ise.fraunhofer.de)

# Motivation

## Characterization of local rear contacts



# Motivation

## State of the art

Parameters known to affect local contact and void formation

- Width of laser opening [1, 5]
  - Particles size in Al paste [2]
  - Si content in Al paste [3, 4, 5]
  - Al paste thickness and confined printing [6, 7, 8]
- Firing profile
    - Temp. plateaus before peak zone [9]
    - Cooling rate [2]
    - Heating rate [2]

### References

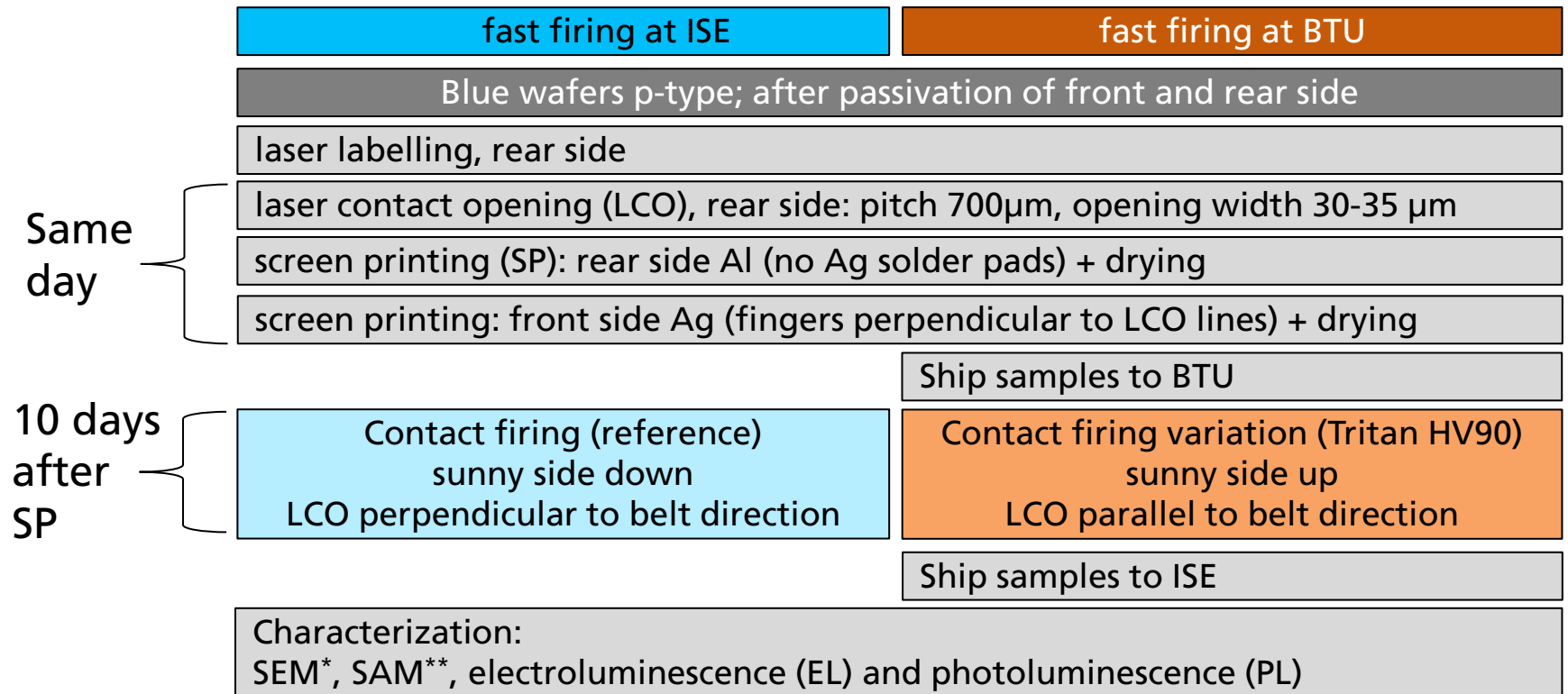
- [1] E. Urrejola, Met. Workshop 2011.
- [2] K. Dressler, IEEE JPV 2016.
- [3] M. Rauer, IEEE EDL 2011.
- [4] Y. Chen, IEEE PVSC 2014.
- [5] T. Lauermann, PIP 2015.
- [6] C. Kranz, IEEE JPV 2015.
- [7] T. Dullweber, PIP 2015.
- [8] D. Lin, IEEE PVSC 2014.
- [9] D. Chen, EU-PVSEC 2013.

# Motivation

## Purpose of the work

- Comparison of different firing profiles and
- Comparison of different characterization methods for local contacts

# Experiment layout



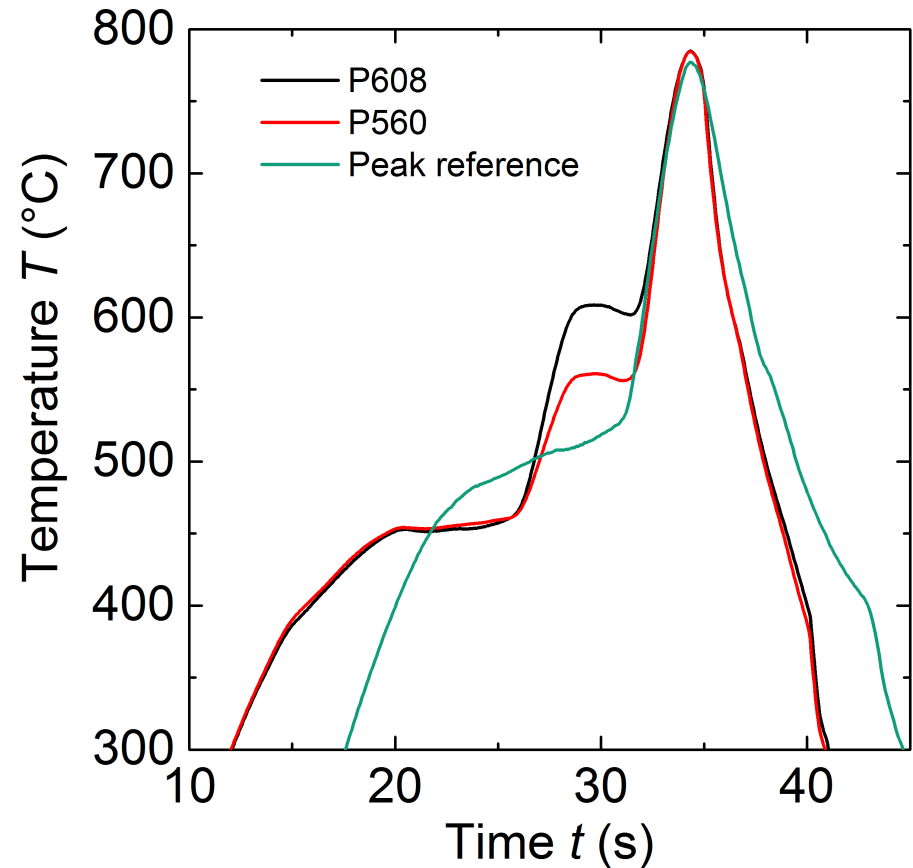
\*SEM: Scanning Electron Microscopy

\*\*SAM: Scanning Acoustic Microscopy

# Firing Profiles

## Pre-plateau

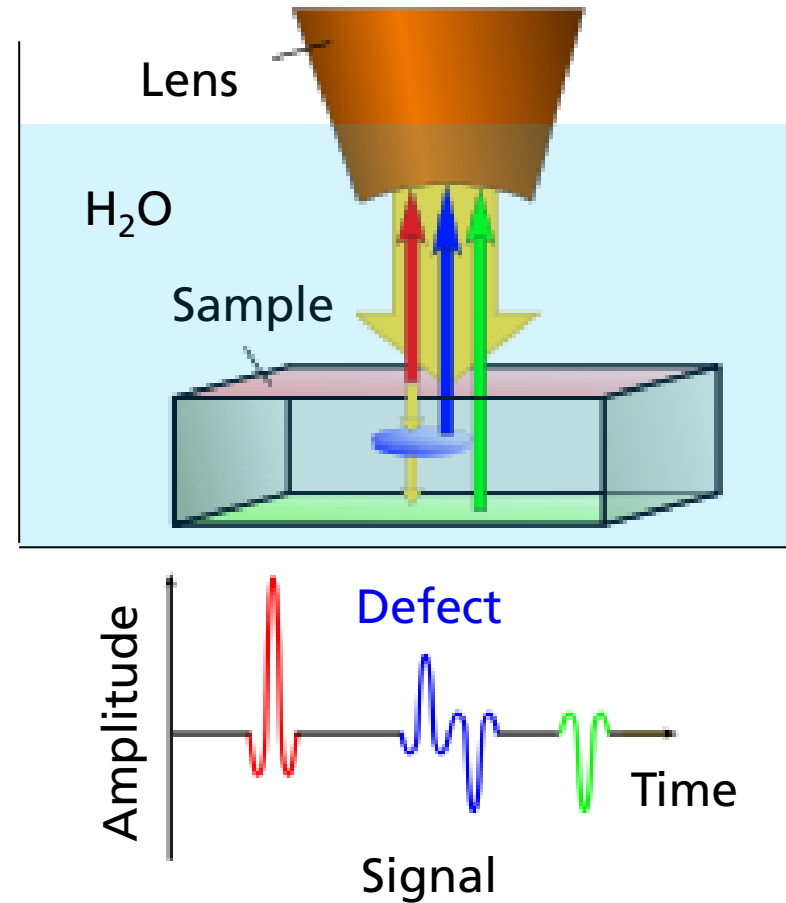
- Idea: lowering the Si concentration gradient at the Al/Si interface by saturation of Al with Si
- Comparison of three firing profiles
  - BTU: Plateau of 608°C for 3s before peak („P608“)
  - **BTU**: Plateau of 560°C for 3s before peak („P560“)
  - **ISE**: Peak reference



# Pre-Plateau

## Scanning acoustic microscopy (SAM)

- Scanning acoustic microscopy for void detection at local rear contacts
- Sound reflectance at voids
- Time consuming measurements in water (10-30 min per image)



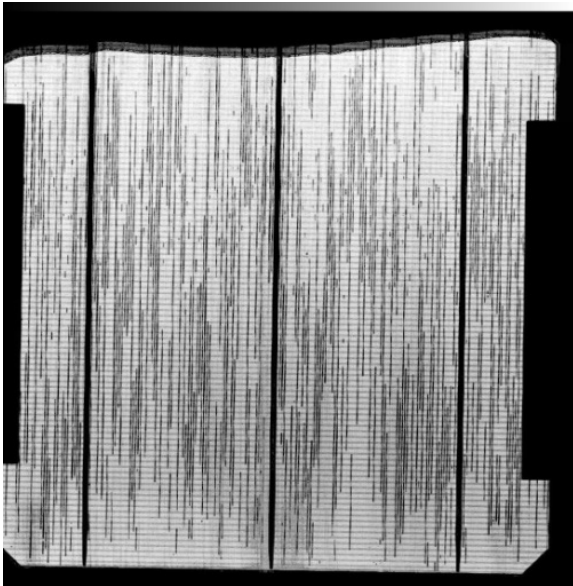
Source: after wikipedia.de



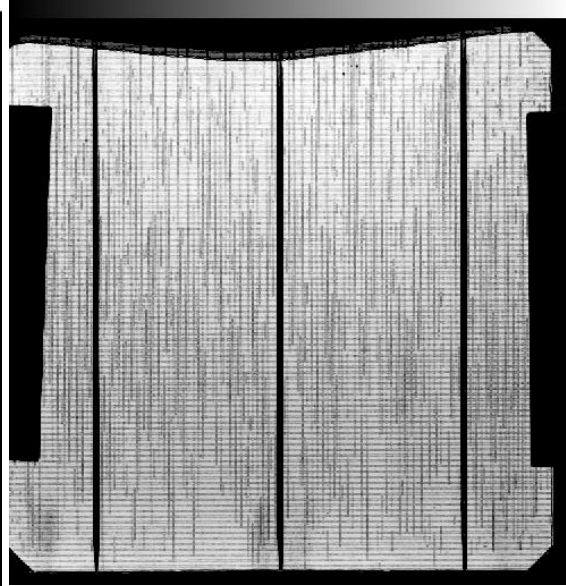
# Pre-Plateau

## Scanning acoustic microscopy (SAM)

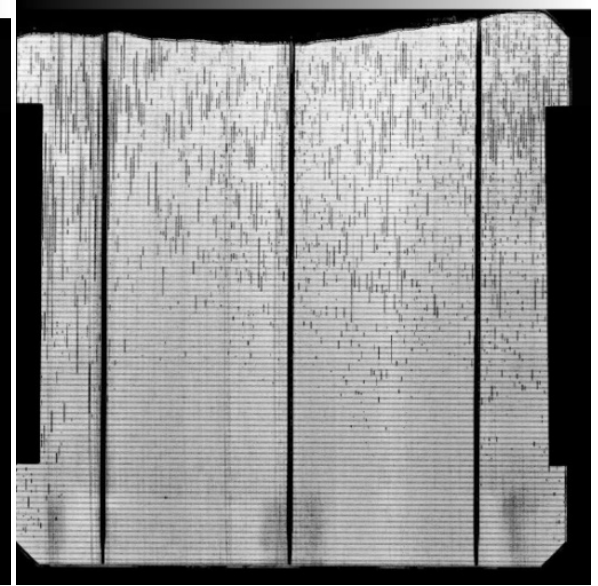
Peak reference



P560



P608



- Lots of voids
- Voids of several cm

➔ SAM ideal tool for void analysis, but not inline capable

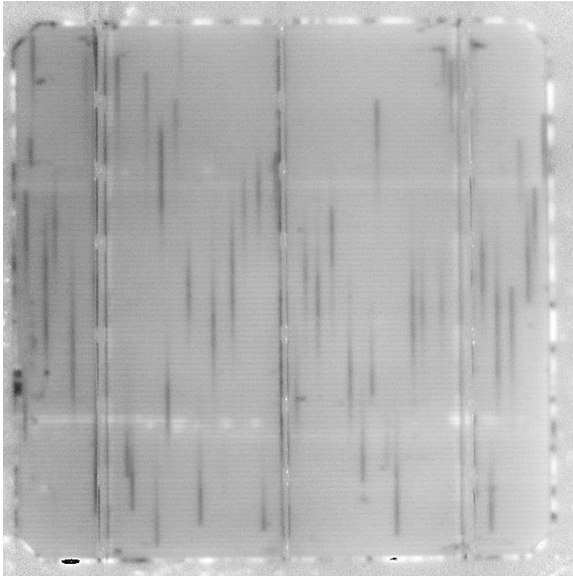
- Void density and length similar to peak profile

- Lowest void density
- Interrupted voids
- Voids only on last half during firing ( $T$  effect) [1]



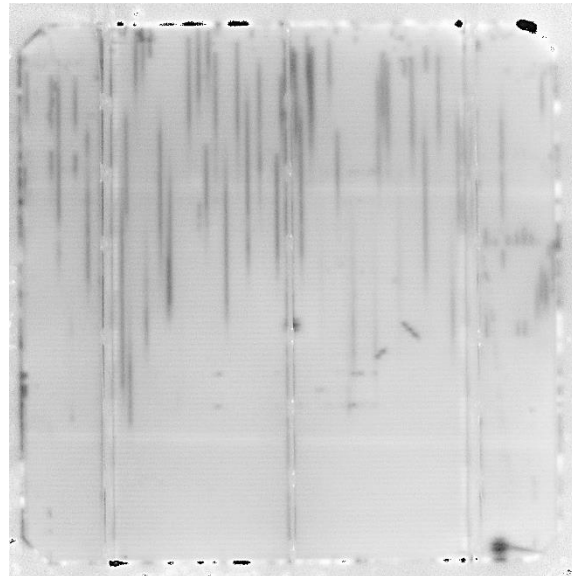
# Pre-Plateau Photoluminescence (PL)

Peak reference



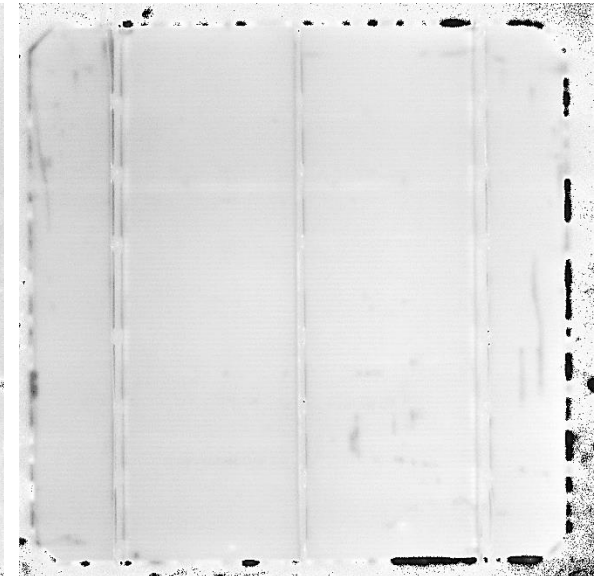
- Recombination only locally increased

P560



- High recombination only in upper half

P608

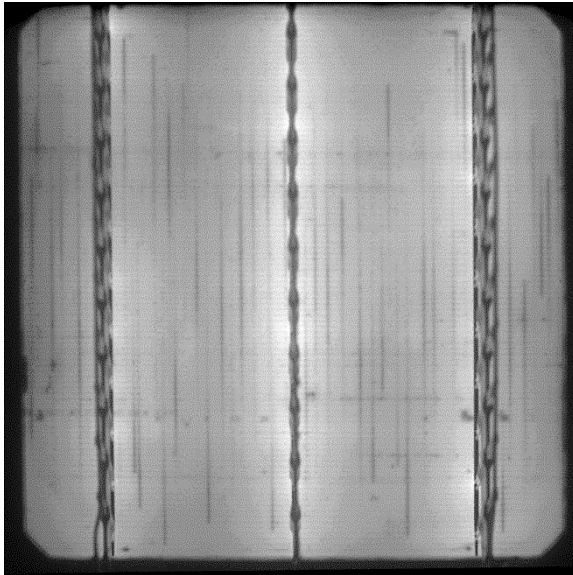


- Homogeneous appearance in PL

- ➔ Not all voids are detrimental
- ➔ Some voids are recombination active
- ➔ Measurement time of ~1s

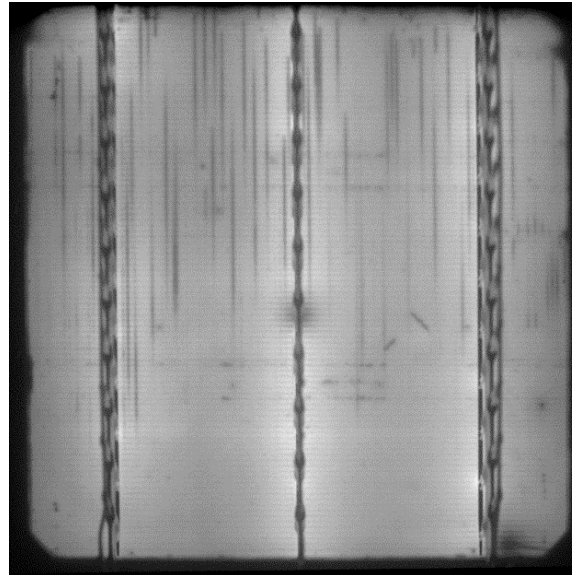
# Pre-Plateau Electroluminescence (EL)

Peak reference



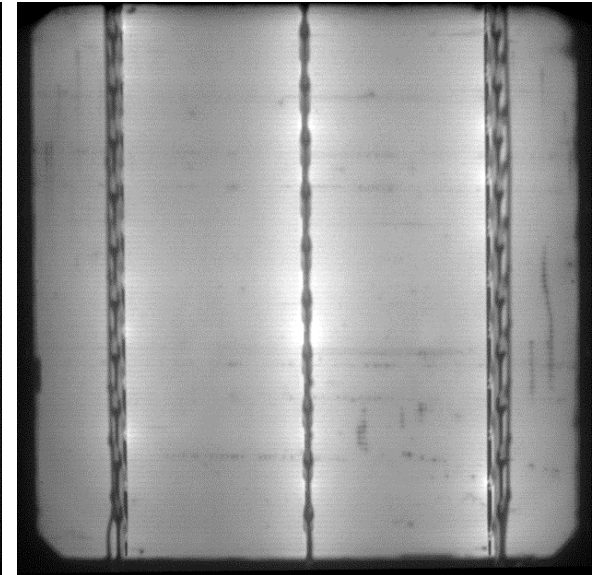
■ Contact resistance only locally increased

P560



■ High contact resistance only in upper half

P608



■ Homogeneous appearance in EL

→ Voids might lead to locally increased series resistance values [1], or again effect of increased recombination

→ Measurement time of ~1s

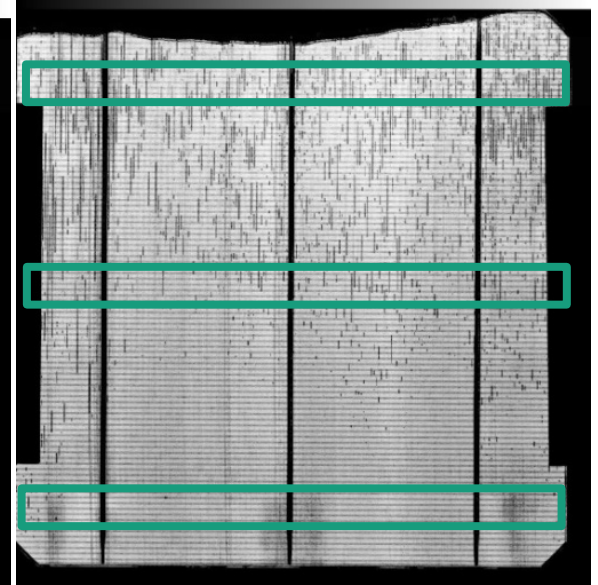
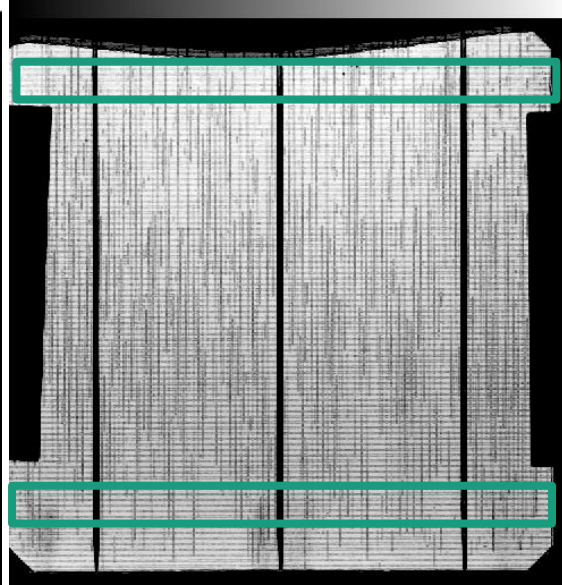
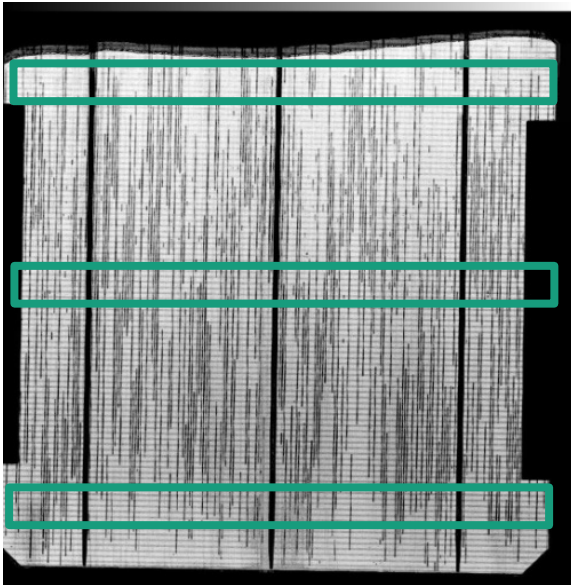
# Pre-Plateau

## Cuts for SEM characterization

Peak reference

P560

P608



- Cross sections at three or two cuts from each wafer analyzed by SEM

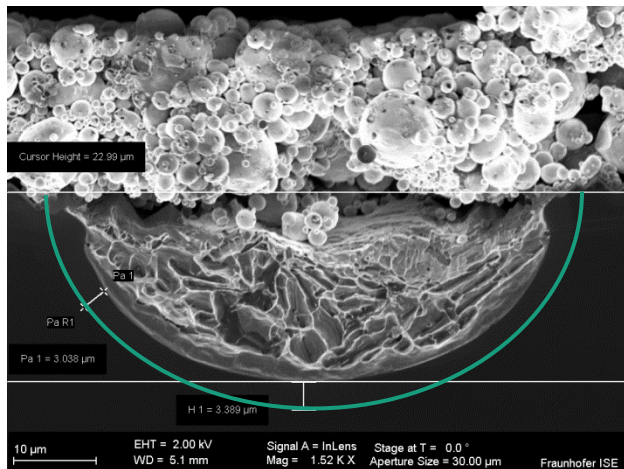


# Pre-Plateau

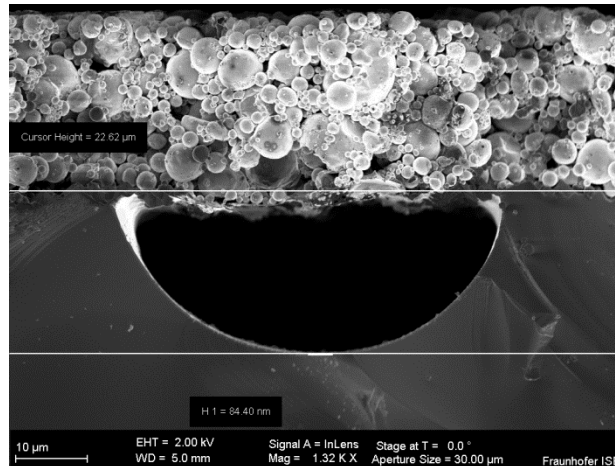
## Scanning electron microscopy (SEM)

### ■ 3 types of contacts

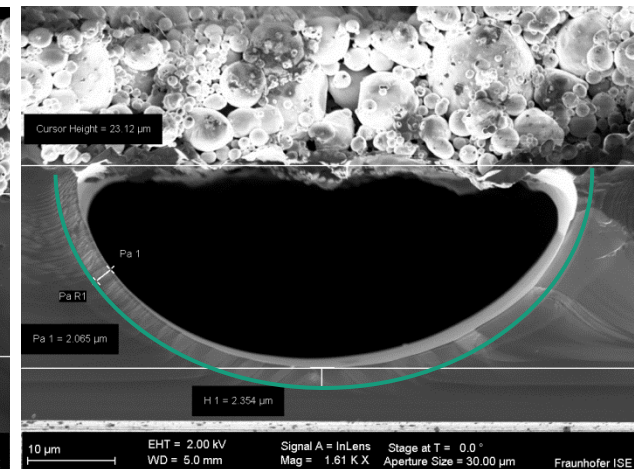
Filled contact, with BSF



Void, without BSF



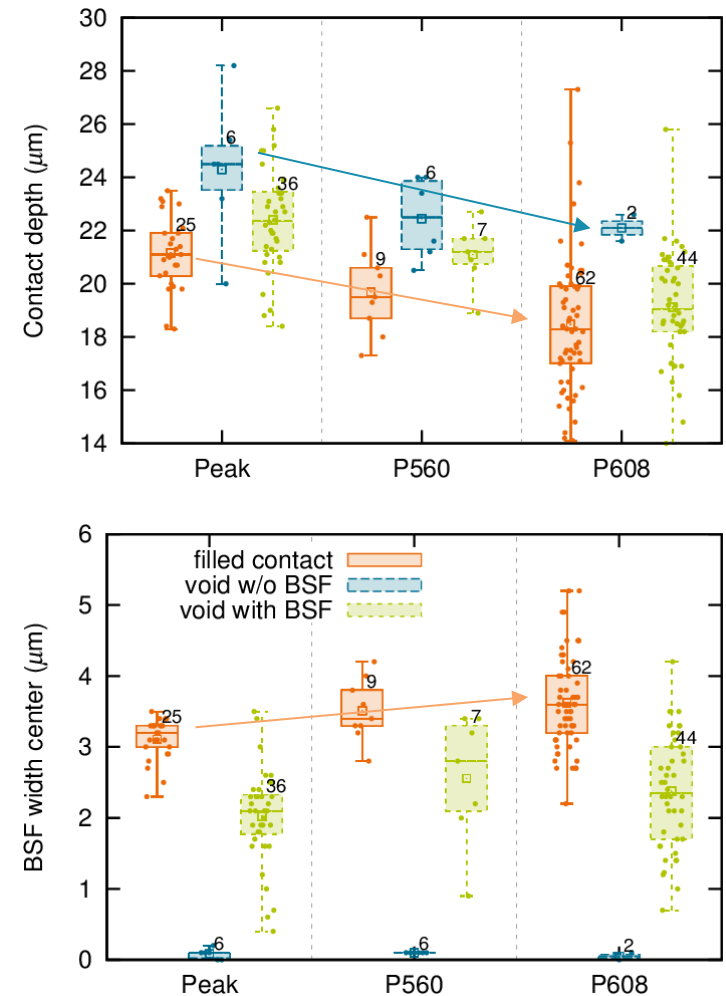
Void, with BSF



# Pre-Plateau

## SEM contact analysis

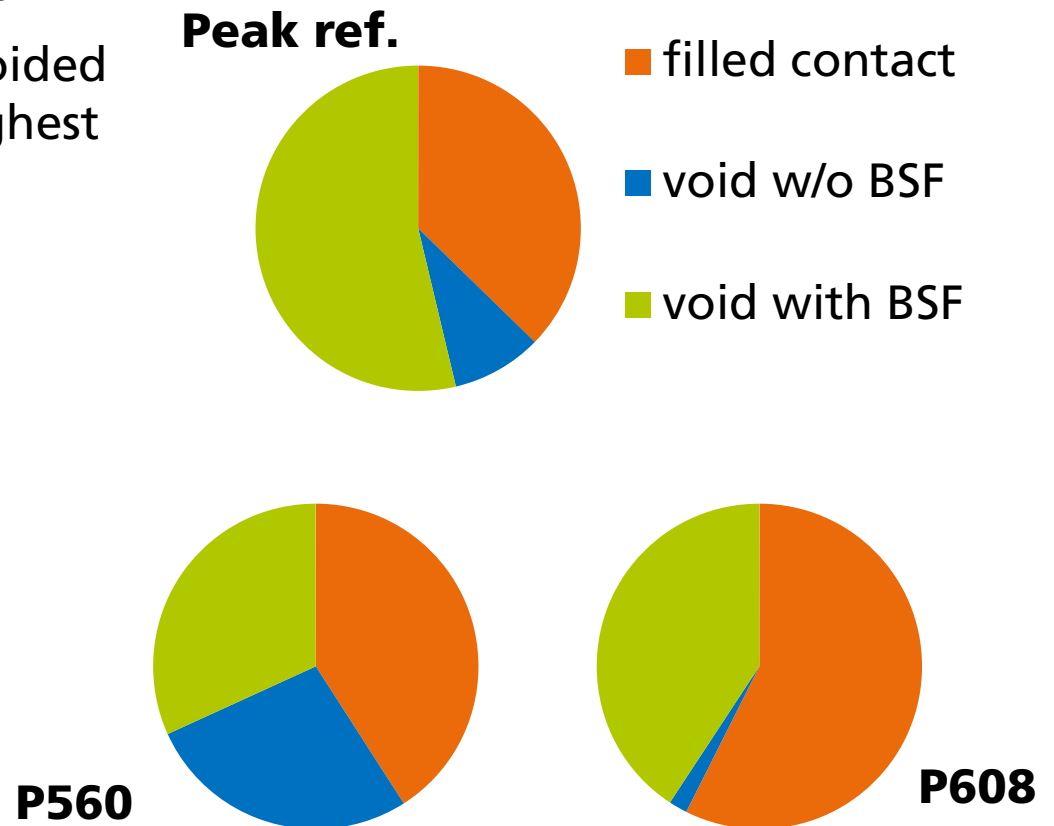
- Contact depth
    - Voided contacts are deeper, especially without BSF
    - Decreases for higher plateau temperatures
  - BSF width
    - Deeper for filled contacts [1]
    - Increases for higher plateau temperatures
- ➔ Pre-plateau at 608°C yields lowest contact depth and thickest BSF



# Pre-Plateau

## SEM contact analysis

- Distribution of contacts types
- P608 yields lowest ratio of voided contacts without BSF and highest ratio of filled contacts



# Summary

## Pre-plateau

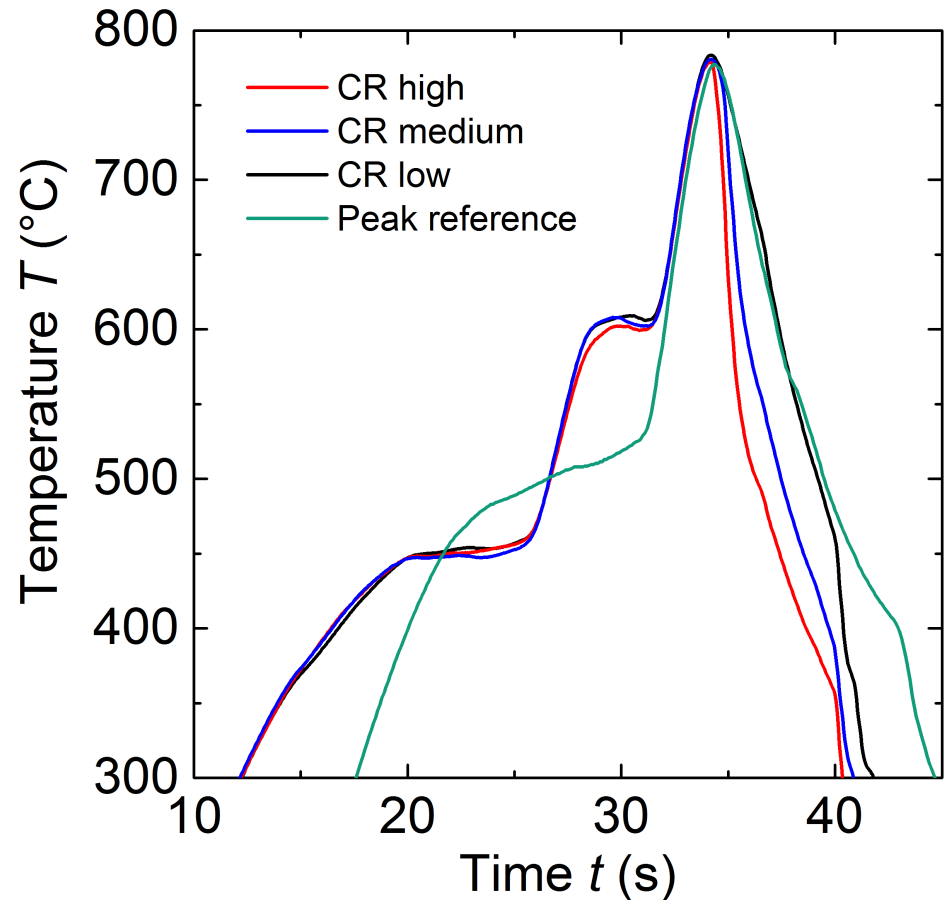
- Voids directly confirmed by SAM
- Correlation with SEM, PL and EL images realized
- Implementation of a 600°C plateau considerably reduces void formation in PERC cells and yields interrupted voids
- Recombination at voided contacts effectively suppressed by thick BSF



# Firing Profiles

## Cooling rate variation

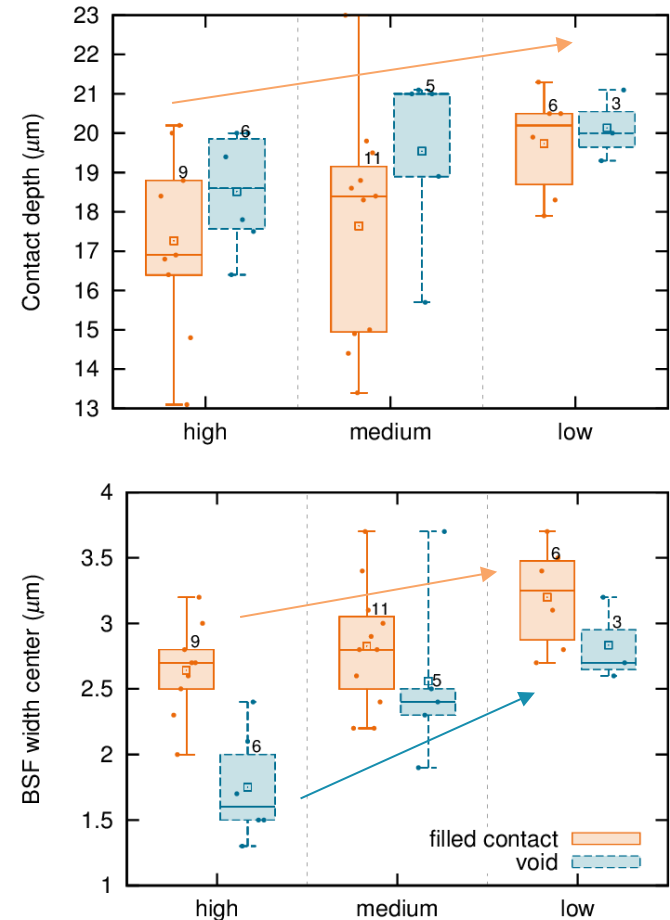
- Idea: allow Si to diffuse back into local contacts
- P608 as starting process
- Cooling rate from  $T_{\max}$  until 577°C
  - **BTU:** High -173 K/s
  - **BTU:** Medium -106 K/s (P608)
  - **BTU:** Low -58 K/s
  - **ISE:** Peak -61 K/s



# Impact of Cooling Rate

## SEM contact analysis

- Measurements on top region of wafer
- Lower cooling rate
  - Increases contact depth
  - Increases width of BSF, especially for voided contacts
- ➔ Low cooling rates (-60K/s) beneficial for achieving thick BSFs
- ➔ Applied cooling rate still relevant for industrial manufacturing



# Impact of Cooling Rate

## SEM contact analysis

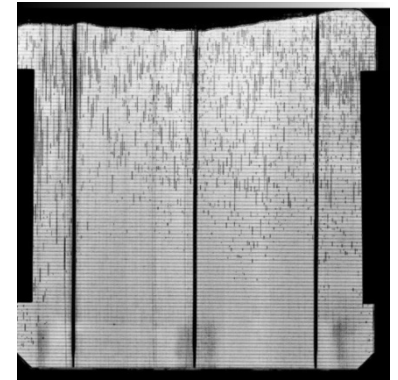
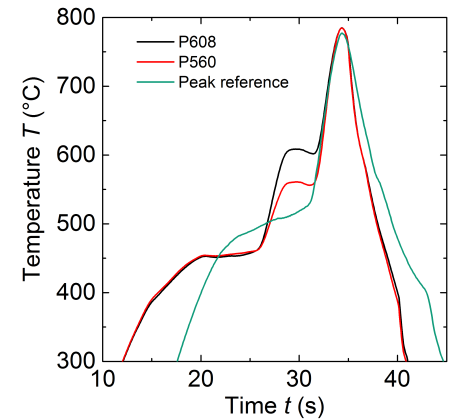
- Counting of voids and filled contacts at SEM cross section cuts

| Plateau | Cooling rate | Contacts investigated | Ratio of voided contacs |
|---------|--------------|-----------------------|-------------------------|
| 600°C   | High         | 66                    | 24%                     |
| 600°C   | Medium       | 76                    | 20%                     |
| 600°C   | Low          | 141                   | 15%                     |
| Peak    | Low          | 439                   | 41%                     |

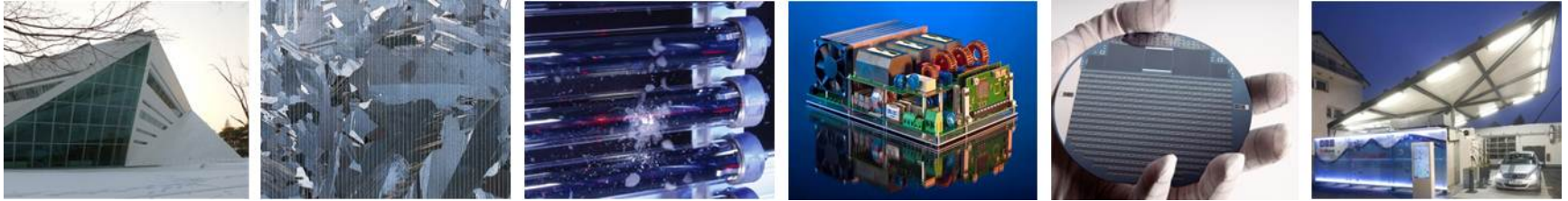
- ➔ Low cooling rates clearly reduce the number of voids
- ➔ 600°C plateau before firing strongly reduces void appearance compared to ISE peak reference process
- ➔ Impact of additional plateau is stronger than cooling rate

# Summary

- Different fast firing profiles for PERC solar cell fabrication have been developed
- Local contacts investigated by a combination of SEM, SAM, EL, PL
- Void reduction shown by both pre-plateau above 600°C and low cooling rates
- Electroluminescence identified as fast method for evaluating quality of local rear contacts



# Thank you for your attention!



... my colleagues at Fraunhofer ISE

... our industry partner BTU and German ministry for funding

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